Erratum The decoration of surface flaws in glass

R. ADAMS, P. W. McMILLAN

Department of Physics, University of Warwick, Coventry, UK J. Mater. Sci. **12** (1977) 2544–2546

Figure 1, page 2545, was incorrectly printed. The correct version is given below.

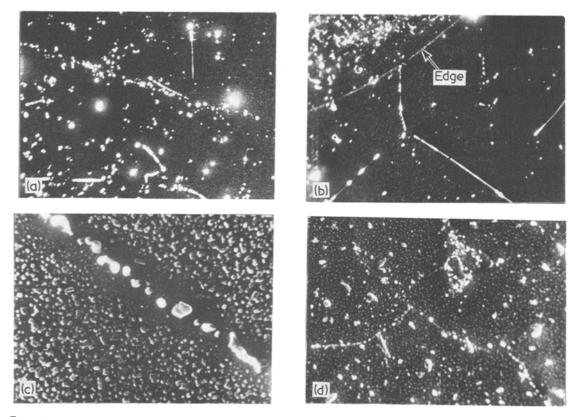


Figure 1 Decoration of float glass specimens by gold deposition and vacuum heat-treatment. Gold sputtered by argon beam bombardment at 6 kV accelerating potential for 5 min (ion beam current density, $3.0 \times 10^{-3} \,\mu A \,\mathrm{m}^{-2}$). (a) "As received" float surface. Substrate temperature $500 \pm 10^{\circ} C$ (× 130). (b) "As received" float surface showing fracture edge. Substrate temperature $500 \pm 10^{\circ} C$ (× 280). (c) "As received" float with scratch mark. Substrate temperature $400 \pm 10^{\circ} C$ (× 2310). (d) Polished surface (6 μ m diamond lapping following initial grinding using 600 grit silicon carbide). Substrate temperature $500 \pm 10^{\circ} C$ (× 5040).